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LAMPIRAN 1

1. Program Simulasi

```
clear
clc

//Nama Atom bahan
Na=6*10^23
E=10//Energi Kinetik
Rho=2.7//Densitas
A=27//nomor massa
Zm=13//nomor atom
N=1000//Jumlah Elektron Awal
m=1
t=2//Jumlah Iterasi(Tunggal)
tebal=1*(1E8)//Dalam Satuan Nano Meter

X=zeros(N,2)
Y=zeros(N,2)
Z=zeros(N,2)
c=sqrt(2*E/m)
J=(9.67*Zm+(58.5/Zm^0.19))*10^-3//potensial ionisasi
alfa=3.4*(10^-3)*(Zm^0.67/E)//screening factor
cros=((5.21*(10^-
21))*(Zm^2/E^2)*(4*pi/(alfa*(1+alfa)))*((E+511/E+1024)^2))//rutherford
elastic cross section
RND=rand(N,t)
cospi=1-((2*alfa*RND)/(1+alfa-RND))//Sudut Hamburan
lambda=(A/Na*Rho*cros)*(10^7)//Jarak Bebas Rerata
step=-lambda*log(RND)//Jarak Hamburan satu dengan yang lain
sins=sqrt(1-cospi.*cospi)
psi=2*pi*RND//sudut azimuth
S=(-78500)*(Zm/(A*E))*log((1.66*(E+(0.85*J)))/J)//Daya Perlambatan
for mt=2:t//Iterasi Mulai
cz(:,mt-1)=c*cos(psi(:,mt-1))
cx(:,mt-1)=c*sin(psi(:,mt-1)).*cospi(:,mt-1)
cy(:,mt-1)=c*sin(psi(:,mt-1)).*sins(:,mt-1)
cz=abs(cz)
An=sqrt(1+(An.*An))
An(:,mt-1)=An(:,mt-1).*sins(:,mt-1)
Am(:,mt-1)=An(:,mt-1).*Am(:,mt-1).*sins(:,mt-1)
Am(:,mt-1)=cos(psi(:,mt-1))
```



```

V4(:,mt-1)=sin(psi(:,mt-1))
ca(:,mt-1)=(cx(:,mt-1).*cospi(:,mt-1))+(V1(:,mt-1).*V3(:,mt-1))+(cy(:,mt-1)
).*V2(:,mt-1).*V4(:,mt-1))
cb(:,mt-1)=(cy(:,mt-1).*cospi(:,mt-1))+(V4(:,mt-1).*((cz(:,mt-1).*V1(:,mt-1))-
(cx(:,mt-1).*V2(:,mt-1))))
cc(:,mt-1)=(cz(:,mt-1).*cospi(:,mt-1))+(V2(:,mt-1).*V3(:,mt-1))-(cy(:,mt-1)
).*V1(:,mt-1).*V4(:,mt-1))
for mN=1:1:N
    if Z(mN,mt-1)<= tebal
X(mN,mt)=X(mN,mt-1)+step(mN,mt-1).*ca(mN,mt-1)
Y(mN,mt)=Y(mN,mt-1)+step(mN,mt-1).*cb(mN,mt-1)
Z(mN,mt)=Z(mN,mt-1)+abs(step(mN,mt-1).*cc(mN,mt-1))
end
    if Z(mN,mt-1)> tebal
X(mN,mt)=X(mN,mt-1)
Y(mN,mt)=Y(mN,mt-1)
Z(mN,mt)=Z(mN,mt-1)
end
end
mt=1
for mt1=2:1:t
    for mt2=1:1:N

        mt=mt+1
end
end

for mt=1:1:N
    if Z(mt,t)>tebal

        end
end

for mt=1:1:N*(t-1)

end
Zhd=Z(:,t)
Zd=abs(Zhd)
zmd=min(min(Zhd))
zMd=max(max(Zhd))

```



```

):
:1:40
c,1)=0
c,1)=1*(mk-0.5)

```

```
for m=1:1:N
    if Zhd(m,1)>(mk-1)*l
        if Zhd(m,1)<mk*l
            kol(mk,1)=kol(mk,1)+1
        end
    end
end
end
end
plot(e11,kol,)
```

